Temperature-dependent resistivity of suspended graphene

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In this paper we investigate the electron-phonon contribution to the resistivity of suspended single-layer graphene. In-plane as well as flexural phonons are addressed in different temperature regimes. We focus on the intrinsic electron-phonon coupling due to the interaction of electrons with elastic deformations in the graphene membrane. The competition between screened deformation potential vs fictitious gauge-field coupling is discussed together with the role of tension in the suspended flake. In the absence of tension, flexural phonons dominate the phonon contribution to the resistivity at any temperature T with a $T^{5/2}$ and T^2 dependence at low and high temperatures, respectively. Sample-specific tension suppresses the contribution due to flexural phonons, yielding a linear temperature dependence due to in-plane modes. We compare our results with recent experiments.

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I. INTRODUCTION

In recent years the discovery of graphene,^{1,2} a monolayer of carbon atoms arranged in a honeycomb lattice, stimulated an unprecedented interest from physicists belonging to different communities. Electrons in graphene behave as massless Dirac fermions, as confirmed by their peculiar quantum Hall effect.^{1,2} In parallel, graphene represents the only existing two-dimensional (2D) conducting membrane embedded in three-dimensional space. This feature became most prominent with the experimental realization of suspended graphene devices.^{3,4} The latter allow for the investigation of the intrinsic properties of the material, unperturbed by the presence of a substrate. Thus, suspended graphene offers the unique possibility of exploring a system involving at once features of quantum electrodynamics as well as of hard and soft condensed-matter physics.⁵

For a long time the very existence of 2D membranes was thought to be impossible^{6,7} due to their tendency toward spontaneous crumpling. Indeed, at harmonic level, the elastic theory of flat 2D membranes yields divergent fluctuations of the angles of the normal vectors to the membrane, due to thermal fluctuations of flexural (out-of-plane) phonons. It was later understood that the nonlinear coupling between stretching and bending energies hardens the bending stiffness at long wavelengths and stabilizes the flat phase.^{8–10}

It was soon realized that mechanical deformations of graphene sheets affect the electronic properties by inducing coexistent scalar and (fictitious or synthetic) gauge fields in the effective low-energy Dirac Hamiltonian.^{11–13} Recently this issue became of special relevance and stimulated the emergence of the so-called strain-engineering community, aimed at controlling the electronic properties of graphene by suitably engineering the deformations.^{14,15}

Suspended membranes show flexural deformations which are typically extremely soft compared to in-plane ones. It may be tempting to conclude that the former should dominate the low-energy electromechanical properties of suspended graphene due to their large density of states (DOS). This effect is balanced by the strength of the electron-phonon coupling in graphene. While in-plane phonons show a conventional linear coupling, the intrinsic electron-phonon coupling of the flexural modes is quadratic.^{10,12} This feature is protected by the reflection symmetry with respect to the plane, as the effect of out-of-plane modes cannot depend on the sign of the deformations. Thus, we find an interesting competition between hard-to-excite but strongly coupled inplane phonons and soft but weakly coupled flexural ones.

From an experimental point of view, this competition can be addressed, e.g., by transport measurements analyzing the temperature-dependent resistivity $\Delta\rho$. Indeed, at high enough electron concentrations and for not too low temperatures (where quantum effects become prominent¹⁶), $\Delta\rho$ is ascribed to electron-phonon scattering. Recent measurements^{17–19} show a $\Delta\rho$ scaling linearly with temperature *T*. This behavior is compatible with the expectations for longitudinal in-plane phonons^{20,21} at $T > T_{BG}^{(l)}$ (with $T_{BG}^{(l)}$ the related Bloch-Grüneisen temperature) as if the flexural phonon contribution were irrelevant. In addition, nonsuspended samples¹⁸ show a density-independent $\Delta\rho$ while suspended graphene¹⁹ exhibit a density dependence which has not been addressed so far.

In a previous paper¹⁰ we investigated the low-temperature dependence of the resistivity of suspended graphene in the absence of tension and found that flexural modes should actually dominate over the in-plane ones yielding a $T^{5/2} \log T$ dependence. Motivated by the experimental puzzles above, here we further analyze the different contributions of inplane vs flexural phonons to the temperature-dependent resistivity by exploring the high-temperature regime and addressing further issues related to nonuniversal factors, like contact-induced tension in the membrane. In particular we investigate whether flexural modes keep dominating the Tdependence of the resistivity also at high temperatures and how tension affects their contribution with respect to inplane phonons. We discuss the dependence of the resistivity on temperature as well as on electron density in light of the recent experimental findings.

The structure of the paper is as follows. In Sec. II we introduce the basic description of the electronic and phononic properties of graphene to be employed in the rest of the paper. In Sec. III we discuss the in-plane vs flexural phonon contributions to the resistivity within a Boltzmann approach. We deduce the temperature and density dependence of the resistivity $\Delta \rho$ in the different regimes where

acoustic phonons are relevant. We also comment on the effect of screening in the density dependence of the electronphonon resistivity. Finally, we conclude in Sec. IV.

II. ELECTRONS AND PHONONS IN GRAPHENE

A. Electronic properties

In this paper we consider the scattering between electrons in graphene and long-wavelength phonon modes. We can thus treat the two Dirac cones independently and focus on the effective low-energy Dirac Hamiltonian^{22,23}

$$H = \hbar v \,\boldsymbol{\sigma} \cdot \mathbf{k},\tag{1}$$

where $v \simeq 10^6$ m s⁻¹ denotes the Fermi velocity and the 2D wave vector \mathbf{k} is measured from the relevant Dirac point. The Hamiltonian in Eq. (1) acts on two-component spinors $(u_{A\mathbf{k}}, u_{B\mathbf{k}})$ of Bloch amplitudes in the space spanned by the two inequivalent honeycomb sublattices (A-B). The components of the vector $\boldsymbol{\sigma}$ are the Pauli matrices in the sublattice space. The real spin degree of freedom does not play a role here and will be ignored. The electronic spinor eigenstates $|\mathbf{k}\rangle$ with chirality $s = \boldsymbol{\sigma} \cdot \mathbf{k} / |\mathbf{k}| = \pm 1$ have energy $\boldsymbol{\epsilon}_{\mathbf{k}} = s\hbar v |\mathbf{k}|$. Their real-space representation is $\langle \mathbf{r} | \mathbf{k} \rangle$ =1/ $\sqrt{2}(1, s \exp[i\phi_{\mathbf{k}}])\exp[i\mathbf{k}\cdot\mathbf{r}]$ with **r** the position vector in the 2D plane and $\phi_{\mathbf{k}}$ the angle of the vector \mathbf{k} with respect to the x axis fixed along the armchair direction of the graphene lattice.

B. Phononic properties

The mechanical distortions of graphene are described by the vector field $\mathbf{u}(\mathbf{r})$ and by the scalar field $h(\mathbf{r})$ associated with in-plane and flexural (out-of-plane) deformations, respectively. The physics of the mechanical distortions is captured by the elastic Lagrangian density

$$\mathcal{L} = \mathcal{L}_{\text{stretch}} + \mathcal{L}_{\text{bend}},$$
$$\mathcal{L}_{\text{stretch}} = \frac{\rho_0}{2} \dot{\mathbf{u}}^2 - \mu u_{ij}^2 - \frac{1}{2} \lambda u_{kk}^2,$$
$$\mathcal{L}_{\text{bend}} = \frac{\rho_0}{2} \dot{h}^2 - \frac{1}{2} \kappa (\nabla^2 h)^2 - \frac{1}{2} \gamma (\nabla h)^2$$
(2)

with contributions coming from stretching and bending energies. Here ρ_0 is the mass density of graphene and

$$u_{ij} = \frac{1}{2} [\partial_i u_j + \partial_j u_i + (\partial_i h)(\partial_j h)]$$
(3)

the strain tensor²⁴ with $i, j \in \{x, y\}$. The Lamé coefficients λ and μ characterize the in-plane rigidity of the lattice while κ is the bending stiffness and γ is a sample-specific coefficient associated with tension induced by the edges of the sample.²⁵ Notice that the $\gamma(\nabla h)^2$ term breaks rotational symmetry which would be obeyed in the absence of tension. We also find it convenient to use the alternative notation $x^{(\nu)}$ with $\nu = l, t$ for the longitudinal and transverse components of the in-plane displacements h.

In the harmonic approximation the Lagrangian above yields two in-plane phonon modes (longitudinal l and transverse t) and one flexural branch (h) with dispersions

$$\omega_{\mathbf{q}}^{(l)} = v^{(l)}q,$$

$$\omega_{\mathbf{q}}^{(t)} = v^{(t)}q,$$

$$\omega_{\mathbf{q}}^{(h)} = \sqrt{(\gamma q^2 + \kappa q^4)/\rho_0}$$
(4)

and group velocities $v^{(l)} = [(2\mu+\lambda)/\rho_0]^{1/2} \simeq 2 \times 10^4$ m/s and $v^{(t)} = [\mu/\rho_0]^{1/2} \simeq 1.3 \times 10^4$ m/s. At long wavelengths (with respect to a = 1.42 Å, the graphene lattice spacing), in-plane phonons have a linear dispersion as Goldstone modes associated with the breaking of translational invariance in the plane. In contrast, flexural modes have a quadratic dispersion in the absence of tension. Tension introduces a new wavevector scale $q_* = (\gamma/\kappa)^{1/2}$ discriminating a tension-induced linear dispersion at low momenta from the quadratic dependence at $q > q_*$

$$\omega_{\mathbf{q}}^{(h)} \simeq \alpha q \quad \text{for } q \ll q_*,$$

 $\omega_{\mathbf{q}}^{(h)} \simeq \beta q^2 \quad \text{for } q \gg q_*$

with $\alpha = (\gamma/\rho_0)^{1/2}$ and $\beta = (\kappa/\rho_0)^{1/2}$. Correspondingly, the DOS for in-plane modes is linear in energy ϵ while that for flexural phonons is linear in energy up to $\hbar \omega_{q_*}^{(h)}$ and independent of energy for $\epsilon > \hbar \omega_{q_*}^{(h)}$. As we will show, the DOS reduction induced by tension is the basic mechanism suppressing the contribution of flexural phonons relative to the tension-independent in-plane ones.

In the following it will be useful to Fourier transform the phononic displacements $x^{(\nu)}(\mathbf{r})$ (with $\nu = l, t, h$) as $x^{(\nu)}(\mathbf{r}) = \sum_{\mathbf{q}} x_{\mathbf{q}}^{(\nu)} \exp[i\mathbf{q}\cdot\mathbf{r}]$. The normal modes can then be expressed as $x_{\mathbf{q}}^{(\nu)} = \xi_{\mathbf{q}}^{(\nu)}(a_{\mathbf{q}}^{(\nu)} + a_{-\mathbf{q}}^{(\nu)\dagger})$ with $\xi_{\mathbf{q}}^{(\nu)} = [\hbar/2M\omega_{\mathbf{q}}^{(\nu)}]^{1/2}$ the oscillator length, $a_{\mathbf{q}}^{(\nu)}$ the annihilation operator for the mode ν at wave number \mathbf{q} and M the total oscillator mass per unit area.

C. Electron-phonon coupling

In this paper we focus on intrinsic coupling mechanisms between electrons and phonons due to the effect of deformations on the electronic Hamiltonian. Other sample-specific mechanisms exist, e.g., due to the capacitive coupling between a backgate and electrons in suspended graphene or due to buckling of the membrane (which breaks the reflection symmetry of the membrane), but these are beyond the scope of the present work.

The intrinsic coupling between electrons and deformations is related to the variation in areas and lengths induced in the membrane by specific distortions. As the variations in length or area are described by the components of the strain tensor,²⁴ by examining its form in Eq. (3) one readily concludes that in-plane phonons have a linear coupling to electrons while flexural phonons have a quadratic one, as long as the reflection symmetry with respect to the plane is not broken. We point out that the breaking of reflection symmetry (e.g., via capacitive coupling or via buckling) would yield a nonuniversal linear coupling for flexural modes. In the presence of tension this would effectively result in a samplespecific contribution to the resistivity with identical parametric dependences as for in-plane phonons.

In more detail, the representation of the electron-phonon coupling in the electronic Dirac description of a single valley is given by 10-12

$$V_{e-ph} = \begin{pmatrix} g_1(u_{xx} + u_{yy}) & g_2 f^*[u_{ij}] \\ g_2 f[u_{ij}] & g_1(u_{xx} + u_{yy}) \end{pmatrix}$$
(5)

W

with $f[u_{ij}]=2u_{xy}+i(u_{xx}-u_{yy})$. The diagonal part of the coupling constitutes a scalar deformation potential originating from local area variations. The corresponding bare coupling constant has been estimated to be¹² $g_1 \simeq 20-30$ eV. In addition, distortions which induce no variation in local areas (e.g., pure shear modes) would still couple to electrons via the induced bond-length modulations. These affect the hopping amplitudes between neighboring carbon atoms and induce the off-diagonal terms of Eq. (5) corresponding to a fictitious (or synthetic) gauge field in the Dirac equation. The corresponding coupling constant has been estimated to be¹² $g_2 \simeq 1.5$ eV which is about an order of magnitude weaker than the deformation potential coupling. In the following, we will assume that these estimates are at least roughly correct. However, we emphasize that it would be straightforward to adapt our results to situations where this inequality no longer holds.

It should be noticed, however, that the deformation potential, contrary to the gauge-field coupling, is affected by electronic screening^{26,27} which reduces the coupling constant g_1 . Indeed, if **Q** is the wave vector transferred in the electronphonon coupling, Thomas-Fermi screening of the deformation potential yields the coupling constant

$$g_1^{(sc)}(Q) = g_1 \frac{1}{1 + \mathcal{V}_Q \Pi_Q} = g_1 \frac{Q}{Q + Q_{TF}}$$
 (6)

with $Q = |\mathbf{Q}|$, $\mathcal{V}_{\mathbf{Q}} = 2\pi e^2/Q$ the 2D Coulomb interaction, and $\Pi_{\mathbf{Q}}$ the fermionic polarization. The Thomas-Fermi screening wave vector $Q_{\mathrm{TF}} = 2\pi e^2 \nu_{\mathrm{F}} = \eta \alpha_{\mathrm{f}} k_{\mathrm{F}}$ is expressed via the fine-structure constant of graphene $\alpha_{\mathrm{f}} = e^2/\hbar v \simeq 2$ and the electronic DOS at the Fermi level $\nu_{\mathrm{F}} = \eta k_{\mathrm{F}}/2\pi\hbar v$, with $\eta = 4$ due to the spin and valley degeneracy. For small wave vectors $Q \ll Q_{\mathrm{TF}}$ the deformation potential coupling is thus strongly suppressed. We can identify a crossover wave vector $Q_{\mathrm{GD}} = Q_{\mathrm{TF}}g_2/(g_1-g_2) \ll 2k_{\mathrm{F}}$ below which the gauge-field coupling dominates over the deformation potential.

In summary, the longitudinal in-plane and flexural modes, as they induce local variations in area, couple to electrons via both the deformation potential and the gauge-field mechanisms while transverse in-plane phonons involve pure shear and couple only via the gauge field. At wave vector \mathbf{Q} , these phonon modes are characterized by the coupling matrices

$$V_{e-ph}^{(l)} = w_{\mathbf{Q}}^{(l)}(a_{\mathbf{Q}}^{(l)} + a_{-\mathbf{Q}}^{(l)\dagger}),$$

$$V_{e-ph}^{(l)} = w_{\mathbf{Q}}^{(l)}(a_{\mathbf{Q}}^{(l)} + a_{-\mathbf{Q}}^{(l)\dagger}),$$

$$V_{e-ph}^{(h)} = w_{\mathbf{q}_{1},\mathbf{q}_{2}}^{(h)}(a_{\mathbf{q}_{1}}^{(h)} + a_{-\mathbf{q}_{1}}^{(h)\dagger})(a_{\mathbf{q}_{2}}^{(h)} + a_{-\mathbf{q}_{2}}^{(h)\dagger})$$
(7)

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$$w_{\mathbf{Q}}^{(l)} = iQ\xi_{Q}^{(l)} \begin{pmatrix} g_{1}^{(\mathrm{sc})}(Q) & -ig_{2}e^{i2\Phi} \\ ig_{2}e^{-i2\Phi} & g_{1}^{(\mathrm{sc})}(Q) \end{pmatrix},$$

$$w_{\mathbf{Q}}^{(l)} = iQ\xi_{Q}^{(l)} \begin{pmatrix} 0 & g_{2}e^{i2\Phi} \\ g_{2}e^{-i2\Phi} & 0 \end{pmatrix},$$

$$\overset{(h)}{\underset{\mathbf{q}_{1},\mathbf{q}_{2}}{}} = -\frac{q_{1}q_{2}}{2}\xi_{q_{1}}^{(h)}\xi_{q_{2}}^{(h)} \times \begin{pmatrix} g_{1}^{(\mathrm{sc})}(Q)\cos\phi & -ig_{2}e^{i\psi} \\ ig_{2}e^{-i\psi} & g_{1}^{(\mathrm{sc})}(Q)\cos\phi \end{pmatrix}$$
(8)

in the Dirac description. For flexural modes $\mathbf{Q} = \mathbf{q}_1 + \mathbf{q}_2$ with \mathbf{q}_1 and \mathbf{q}_2 the wave vectors of the two flexural phonons. In the matrices above Φ , ϕ_1 and ϕ_2 are the angles of the vectors \mathbf{Q} , \mathbf{q}_1 , and \mathbf{q}_2 with respect to the *x* axis, respectively, and we defined $\phi = \phi_1 - \phi_2$ and $\psi = \phi_1 + \phi_2$.

III. CONTRIBUTION TO THE RESISTIVITY FROM ELECTRON-PHONON SCATTERING

We now address the electron-phonon contribution to the resistivity of suspended graphene. It is believed that this yields the dominant temperature dependence of the resistivity for the regime of high temperatures involved in recent experiments^{18,19} (50 < T < 300 K). Further mechanisms contributing to the temperature dependence of the resistivity discussed in the literature focus on the ballistic regime,²⁸ on the *T*-dependent screening of Coulomb impurities,²⁹ or on the combined effects of electron-electron interactions and atomic-scale impurities.³⁰

We focus on the high electron-density regime where the Fermi wave vector $k_{\rm F}$ is larger than the inverse mean free path due to disorder and electron-phonon scattering. In this regime a quasiclassical Boltzmann approach to transport can be employed. The linearized Boltzmann equation for the electronic distribution function $f_{\rm k}$ in presence of a constant electric field **E** has the standard form³¹

$$-e\mathbf{E}\cdot\mathbf{v}\frac{\partial f_{\mathbf{k}}^{0}}{\partial\epsilon_{\mathbf{k}}} = C(\varphi_{\mathbf{k}})$$
⁽⁹⁾

with -e the electron charge and $\mathbf{v} = \partial \epsilon_{\mathbf{k}} / \partial(\hbar \mathbf{k})$ the electron velocity. Here we assumed the stationary condition $\partial f_{\mathbf{k}} / \partial t = 0$ as well as spatial uniformity $\partial f_{\mathbf{k}} / \partial \mathbf{r} = 0$ and we denoted by $f_{\mathbf{k}}^0 = (\exp[(\epsilon_{\mathbf{k}} - \mu) / k_{\mathrm{B}}T] + 1)^{-1}$ the equilibrium Fermi-Dirac distribution function with μ the chemical potential. The collision integral on the right-hand side of Eq. (9) depends linearly on the deviation from the equilibrium distribution, expressed through the function $\varphi_{\mathbf{k}}$ as

$$f_{\mathbf{k}} - f_{\mathbf{k}}^{0} = -\frac{\partial f_{\mathbf{k}}^{0}}{\partial \epsilon_{\mathbf{k}}} \varphi_{\mathbf{k}}.$$
 (10)

In the relaxation-time approximation we can express the collision integral as

$$C(\varphi_{\mathbf{k}}) = -\frac{f_{\mathbf{k}} - f_{\mathbf{k}}^{0}}{\tau_{\mathbf{k}}} = \frac{\varphi_{\mathbf{k}}}{\tau_{\mathbf{k}}} \frac{\partial f_{\mathbf{k}}^{0}}{\partial \epsilon_{\mathbf{k}}}$$
(11)

in terms of the transport scattering time τ_k . By direct comparison of Eqs. (9) and (11) we obtain the solution of the Boltzmann equation as

with

$$\varphi_{\mathbf{k}} = -e\mathbf{E} \cdot \mathbf{v}\,\tau_{\mathbf{k}} \propto \cos\,\zeta \tag{12}$$

with ζ the angle between **E** and **v**. Notice that in graphene the modulus of the velocity is independent of wave vector and $\mathbf{v} \| \hat{\mathbf{k}}$. The solution to the linearized Boltzmann equation yields the current density

$$\mathbf{j} = -\eta e \sum_{\mathbf{k}} \mathbf{v} (f_{\mathbf{k}} - f_{\mathbf{k}}^0) = -\eta e^2 \sum_{\mathbf{k}} \frac{\partial f_{\mathbf{k}}^0}{\partial \epsilon_{\mathbf{k}}} \mathbf{v} (\mathbf{E} \cdot \mathbf{v}) \tau_{\mathbf{k}}.$$
 (13)

In the regime $k_{\rm B}T \ll \epsilon_{\rm F}$ (with $\epsilon_{\rm F} = \hbar v k_{\rm F}$ the Fermi energy), $\partial f_{\rm k}^0 / \partial \epsilon_{\rm k}$ is sharply peaked around the Fermi level and the current density can thus be obtained by performing the angular average of over **k** with the scattering time $\tau_{k_{\rm F}}$ evaluated at the Fermi level. As a result, $\mathbf{j} = e^2 v^2 \nu_{\rm F} \tau_{k_{\rm F}} \mathbf{E}/2$, yielding the longitudinal resistivity

$$\rho = \frac{\epsilon_{\rm F}}{n e^2 v^2 \tau_{k_{\rm F}}} \tag{14}$$

with $n = \eta k_{\rm F}^2 / 4\pi$ the electronic density.

We now focus on the collision integral $C(\varphi_k)$ for the scattering of electrons on in-plane and flexural phonons in graphene. By comparison with Eq. (11) we will thus deduce the respective transport scattering time, leading to the resistivity via Eq. (14).

A. In-plane phonons

Let us first consider scattering between electrons and inplane phonons of type ν ($\nu = l, t$ for longitudinal and transverse modes, respectively). The collision integral $C^{(\nu)}(f_k)$ describing the detailed balance of the occupation of an electronic state with wave vector **k** is given by the Fermi golden rule expression

$$C^{(\nu)}(f_{\mathbf{k}}) = \frac{2\pi}{\hbar} \sum_{\mathbf{Q}} W^{(\nu)}_{\mathbf{k}',\mathbf{Q};\mathbf{k}} [f_{\mathbf{k}'}(1-f_{\mathbf{k}})n^{(\nu)}_{\mathbf{Q}} - f_{\mathbf{k}}(1-f_{\mathbf{k}'})(1+n^{(\nu)}_{\mathbf{Q}})] \delta(\boldsymbol{\epsilon}_{\mathbf{k}} - \boldsymbol{\epsilon}_{\mathbf{k}'} - \hbar\omega^{(\nu)}_{\mathbf{Q}}) + \frac{2\pi}{\hbar} \sum_{\mathbf{Q}} W^{(\nu)}_{\mathbf{k}';\mathbf{k},\mathbf{Q}} [f_{\mathbf{k}'}(1-f_{\mathbf{k}})(1+n^{(\nu)}_{\mathbf{Q}}) - f_{\mathbf{k}}(1-f_{\mathbf{k}'})n^{(\nu)}_{\mathbf{Q}}] \delta(\boldsymbol{\epsilon}_{\mathbf{k}} - \boldsymbol{\epsilon}_{\mathbf{k}'} + \hbar\omega^{(\nu)}_{\mathbf{Q}}),$$
(15)

(

where $n_{\mathbf{Q}}^{(\nu)}$ is the distribution function for phonons and the factors $W_{\mathbf{k}';\mathbf{k},\mathbf{Q}}^{(\nu)}$ are given by

$$W_{\mathbf{k}';\mathbf{k},\mathbf{Q}}^{(\nu)} = \delta_{\mathbf{k}',\mathbf{k}+\mathbf{Q}} |\langle \mathbf{k}' | w_{\mathbf{Q}}^{(\nu)} | \mathbf{k} \rangle|^2.$$
(16)

The first term describes the process of absorption of a phonon with wave vector **Q** and energy $\hbar \omega_{\mathbf{Q}}^{(\nu)}$ by an electron with wave vector \mathbf{k}' and the reverse process involving the emission of the phonon by an electron with wave vector \mathbf{k} . In parallel, the second term describes the emission of the phonon by the electron in state $|\mathbf{k}'\rangle$ and the absorption of the phonon by the electron in $|\mathbf{k}\rangle$.

We now proceed to linearize the collision integral above,³¹ making use of Eq. (10). In doing so, we expand $f_{\mathbf{k}'}^0 - f_{\mathbf{k}}^0 = \pm \hbar \omega_{\mathbf{Q}}^{(\nu)} (\partial f_{\mathbf{k}}^0 / \partial \epsilon_{\mathbf{k}})$ for $\epsilon_{\mathbf{k}'} = \epsilon_{\mathbf{k}'} \pm \hbar \omega_{\mathbf{Q}}^{(\nu)}$, valid if $\hbar \omega_{\mathbf{Q}}^{(\nu)} \ll \epsilon_{\mathbf{k}}$. Indeed, although, strictly speaking, phonon scattering is inelastic, acoustic phonons in graphene have a low group velocity with respect to the electrons, which justifies a quasielastic approximation for the scattering rate. We also assume the phonons to always remain in equilibrium.³¹ Summing up the contributions in Eq. (15) we obtain the linearized collision integral³¹

$$C^{(\nu)}(\varphi_{\mathbf{k}}) \simeq \frac{2\pi}{\hbar} \sum_{\mathbf{Q}} 2\omega_{\mathbf{Q}}^{(\nu)} \frac{\partial n_{\mathbf{Q}}^{0(\nu)}}{\partial \omega_{\mathbf{Q}}^{(\nu)}} \frac{\partial f_{\mathbf{k}}^{0}}{\partial \epsilon_{\mathbf{k}}} (\varphi_{\mathbf{k}+\mathbf{Q}} - \varphi_{\mathbf{k}})$$
$$\times |\langle \mathbf{k} + \mathbf{Q} | w_{\mathbf{Q}}^{(\nu)} | \mathbf{k} \rangle|^{2} \delta(\epsilon_{\mathbf{k}+\mathbf{Q}} - \epsilon_{\mathbf{k}}), \qquad (17)$$

where $n_{\mathbf{Q}}^{0(\nu)} = (\exp[\hbar \omega_{\mathbf{Q}}^{(\nu)}/k_{\mathrm{B}}T] - 1)^{-1}$ is the equilibrium Bose-

Einstein distribution. As the standard solution in Eq. (12) yields $\varphi_{\mathbf{k}} \propto \cos \zeta$, we can write

$$\mathcal{L}^{(\nu)}(\varphi_{\mathbf{k}}) \simeq -\varphi_{\mathbf{k}} \frac{\partial f_{\mathbf{k}}^{0}}{\partial \epsilon_{\mathbf{k}}} \frac{2\pi}{\hbar} \sum_{\mathbf{Q}} 2\omega_{\mathbf{Q}}^{(\nu)} \frac{\partial n_{\mathbf{Q}}^{0(\nu)}}{\partial \omega_{\mathbf{Q}}^{(\nu)}} (1 - \cos \theta)$$
$$\times |\langle \mathbf{k} + \mathbf{Q} | w_{\mathbf{Q}}^{(\nu)} | \mathbf{k} \rangle|^{2} \delta(\epsilon_{\mathbf{k}+\mathbf{Q}} - \epsilon_{\mathbf{k}})$$
(18)

with θ the angle between the electronic wave vectors **k** and **k**+**Q**. By direct comparison with Eq. (11), we deduce the transport scattering rate

$$\frac{1}{\tau_{\mathbf{k}}} = -\frac{2\pi}{\hbar} \sum_{\mathbf{Q}} 2\omega_{\mathbf{Q}}^{(\nu)} \frac{\partial n_{\mathbf{Q}}^{0(\nu)}}{\partial \omega_{\mathbf{Q}}^{(\nu)}} (1 - \cos \theta)$$
$$\times |\langle \mathbf{k} + \mathbf{Q} | w_{\mathbf{Q}}^{(\nu)} | \mathbf{k} \rangle|^2 \delta(\epsilon_{\mathbf{k}+\mathbf{Q}} - \epsilon_{\mathbf{k}}). \tag{19}$$

The derivative of the Bose distribution implies that the relevant phonons to be considered have energies up to $\hbar \omega_{\mathbf{Q}}^{(\nu)} \sim k_{\mathrm{B}}T$ and their wave numbers restricted to $Q \leq q_T^{(\nu)}$ with $\hbar \omega_{q_T^{(\nu)}}^{(\nu)} = k_{\mathrm{B}}T$. This can be understood as follows. In absorption processes, it is only these phonons that have a large enough equilibrium occupation while in emission processes, electrons can transfer at most an energy of order $k_{\mathrm{B}}T$ to the phonons due to the Fermi distribution.

In addition, the quasielastic approximation in Eq. (19) demands energy conservation involving only the incoming and outgoing electron energies at the Fermi level. When combined with the single-valley approximation, the quasielasticity implies conservation of chirality. In the following, we



FIG. 1. The on-shell condition forces the incoming and outgoing electron momenta \mathbf{k} and $\mathbf{k}+\mathbf{0}$ on the Fermi circle with $\mathbf{0}$ the phonon-induced scattering wave vector.

thus choose s=1 without loss of generality. The on-shell condition and the relation between momenta and their angles (sketched in Fig. 1) yield

$$\delta(\boldsymbol{\epsilon}_{\mathbf{k}+\mathbf{Q}} - \boldsymbol{\epsilon}_{\mathbf{k}}) = \sum_{\Phi_0} \frac{1}{\hbar v Q |\cos(\theta/2)|} \delta(\Phi - \Phi_0), \quad (20)$$

where Φ_0 denotes the angles between k and Q fulfilling $\cos \Phi_0 = -\sin(\theta/2) = -Q/2k_{\rm F}$. This condition also forces Q $\in [0, 2k_{\rm F}]$. As a result we deduce

$$1 - \cos \theta = 2 \sin^2(\theta/2) = 2\left(\frac{Q}{2k_{\rm F}}\right)^2.$$
 (21)

We thus conclude that the phonon-induced resistivity exhibits a number of temperature regimes in suspended graphene, for two reasons. The first reason is conventional and is associated with the Bloch-Grüneisen temperature $T_{\rm BG}^{(\nu)} = \hbar \omega_{2k_{\rm E}}^{(\nu)} / k_{\rm B}$. When $T \gg T_{\rm BG}^{(\nu)}$, large angle scattering is possible while, at $T \ll T_{BG}^{(\nu)}$, only small-angle scattering is relevant. The second reason is specific to graphene and is associated with the screening dependence of the relevant electron-phonon coupling mechanism. If $T \gg T_{BG}^{(\nu)}$, screening hardly affects the dominant deformation potential contribution to the resistivity while, at small enough temperatures, it suppresses the deformation potential in favor of the gaugefield coupling.

Indeed, in the high-temperature regime $T \ge T_{BG}^{(\nu)}$ the sum over phonon momenta is cut off at $2k_{\rm F}$ and scattering at all angles is possible. Consequently, screening does not significantly affect the deformation potential coupling. The latter yields the dominant contribution to the resistivity for longitudinal phonons with $g_1^{(sc)}(Q) \simeq g_1$ while transverse modes

depend only on the unscreened gauge-field coupling. In contrast, in the regime $T \ll T_{BG}^{(p)}$, the sum is cut off at $q_T^{(\nu)}$ (with $q_T^{(\nu)} \ll 2k_{\rm F}$). This constraint implies dominant small angle scattering $(\theta \ll 1)$, and the term $1 - \cos \theta$ therefore yields the factor $2(q_T^{(\nu)}/2k_{\rm F})^2 \sim (T/T_{\rm BG}^{(\nu)})^2 \ll 1$. In addition, in this regime the deformation potential coupling for longitudinal phonons is strongly screened. We thus identify an inter-mediate regime for $T_{GD}^{(l)} < T < T_{BG}^{(l)}$ (with $T_{GD}^{(l)} = \hbar \omega_{Q_{GD}}^{(l)} / k_{B}$) where small angle scattering is accompanied by a dominant deformation potential. Finally, at low-temperatures $T < T_{GD}^{(l)}$ the scattering rate is dominated by the unscreened gaugefield coupling. As screening does not affect the coupling for transverse phonons, the latter do not show an intermediate temperature regime.

1. Longitudinal phonons

We first turn to the transport scattering rate due to longitudinal in-plane phonons which couple to the carriers through both, a gauge field and the deformation potential. The deformation potential contribution to the scattering rate has been analyzed before for monolayer^{21,32,33} and bilayer graphene.³⁴ Note, however, that while the deformation potential is believed to have a larger bare coupling constant, it is suppressed at long wavelengths due to screening for nonzero doping. Thus, screening leads to temperature regimes in addition to those associated with the Bloch-Grüneisen temperature.

With the coupling matrix in Eq. (8) we deduce

$$\begin{aligned} \langle \mathbf{k} + \mathbf{Q} | w_{\mathbf{Q}}^{(l)} | \mathbf{k} \rangle &= \frac{i Q \xi_{\mathbf{Q}}^{(l)}}{2} \times \left[g_1^{(\mathrm{sc})}(Q) (1 + e^{-i\theta}) \right. \\ &\left. - i g_2(e^{i(2\Phi + \phi_{\mathbf{k}})} - e^{-i(2\Phi + \phi_{\mathbf{k}} + \theta)}) \right] \end{aligned}$$

including both deformation potential and gauge-field couplings. The dominant contributions to the scattering rate [Eq. (19) in the various temperature regimes therefore are

$$\frac{1}{\tau_{k_{\rm F}}} \simeq \frac{32\pi^3}{15} \Gamma' \left(\frac{T}{T_{\rm BG}^{(l)}}\right)^4 \quad \text{for } T \ll T_{\rm GD}^{(l)},$$

$$\frac{1}{\tau_{k_{\rm F}}} \simeq 12\pi^5 \Gamma \left(\frac{2k_{\rm F}}{Q_{\rm TF}}\right)^2 \left(\frac{T}{T_{\rm BG}^{(l)}}\right)^6 \quad \text{for } T_{\rm GD}^{(l)} \ll T \ll T_{\rm BG}^{(l)},$$

$$\frac{1}{\tau_{k_{\rm F}}} \simeq \Gamma f \left(\frac{Q_{\rm TF}}{2k_{\rm F}}\right) \frac{T}{T_{\rm BG}^{(l)}} \quad \text{for } T \gg T_{\rm BG}^{(l)} \qquad (22)$$

with $\Gamma = g_1^2 k_F^2 / 2\hbar \rho_0 v v^{(l)}$, $\Gamma' = \Gamma g_2^2 / g_1^2$, and f(x) a function ful-

filling $f(x \le 1) \simeq 1 - 32x/3\pi$ and $f(x) \ge 1/2x^2$. The T^4 dependence for $T \le T_{GD}^{(l)}$ is due to the gauge-field coupling. It is analogous to the T^5 dependence (Bloch law) for $T \le T_{BG}^{(l)}$ in three dimensions,²⁰ the difference in the power-law stemming from the reduced dimensionality of momentum space.

In the intermediate temperature regime, $T_{GD}^{(l)} \ll T \ll T_{BG}^{(l)}$, the screened deformation potential dominates over the gauge-field coupling. The T^6 dependence originates from the combined effects of screening and small angle scattering.

Finally, the linear temperature dependence for $T \gg T_{BG}^{(l)}$ stems from the high-temperature expansion of the Bose distribution. Since the typical momentum transfers in this regime are of order $2k_{\rm F}$, it is associated with the essentially unscreened deformation potential. This regime turns out to be the most relevant for the interpretation of recent measurements.18,19

2. Transverse phonons

The analysis above can be extended to transverse in-plane phonons. These have a slightly smaller group velocity than longitudinal modes and couple only via the gauge-field mechanism so that screening is not relevant. As a result, the intermediate regime in Eq. (22) is absent. The coupling term in Eq. (8) yields

$$\langle \mathbf{k} + \mathbf{Q} | w_{\mathbf{Q}}^{(t)} | \mathbf{k} \rangle = \frac{i g_2 Q \, \xi_{\mathbf{Q}}^{(t)}}{2} (e^{i(2\Phi + \phi_{\mathbf{k}})} + e^{-i(2\Phi + \phi_{\mathbf{k}} + \theta)}), \quad (23)$$

leading to the scattering rate

$$\frac{1}{\tau_{k_{\rm F}}} \simeq \frac{16\pi^3}{15} \Gamma_{\rm G} \left(\frac{T}{T_{\rm BG}^{(t)}}\right)^4 \quad \text{for } T \ll T_{\rm BG}^{(t)},$$
$$\frac{1}{\tau_{k_{\rm F}}} \simeq \Gamma_{\rm G} \frac{T}{T_{\rm BG}^{(t)}} \quad \text{for } T \gg T_{\rm BG}^{(t)} \tag{24}$$

with $\Gamma_{\rm G} = g_2^2 k_{\rm F}^2 / \hbar \rho_0 v v^{(t)}$. The transverse in-plane phonons thus yield a contribution to the resistivity comparable to the longitudinal ones for $T \ll T_{\rm GD}^{(l)}$ while for higher temperatures they can be neglected to a good approximation.

3. Temperature-dependent resistivity in recent experiments

Recent experiments in graphene highlighted the contribution to the resistivity due to electron-phonon scattering $\Delta \rho$ at $T \gg T_{\rm BG}^{(l)}$.^{18,19} In this regime, using our estimates above, the resistivity due to scattering by in-plane phonons, $\Delta \rho_{\rm in} = \epsilon_{\rm F}/ne^2 v^2 \tau_{k_{\rm F}}$, is dominated by the deformation potential coupling of longitudinal modes and is given by

$$\Delta \rho_{\rm in} \simeq \frac{\pi g_{\rm l}^2 f(Q_{\rm TF}/2k_{\rm F})}{4\hbar\rho_0 e^2 v^2 v^{(l)2}} k_{\rm B} T \simeq \frac{h}{e^2} 2 \times 10^{-8} \tilde{g}_{\rm l}^2 \tilde{T} \qquad (25)$$

in terms of the rescaled quantities $\tilde{g}_1 = g_1 f(Q_{\rm TF}/2k_{\rm F})/{\rm eV}$ and $\tilde{T} = T/{\rm K}$. The contribution to the resistivity due to in-plane phonons is thus linear in temperature and independent of the electron concentration for $T \gg T_{\rm BG}^{(l)}$.

Experiments in nonsuspended samples¹⁸ show a temperature-dependent component of the resistivity compatible with Eq. (25), which is quantitatively consistent with the estimates for the bare deformation potential coupling constant.¹² Suspended graphene devices¹⁹ likewise show a linear *T* dependence, compatible with in-plane phonons, but accompanied by an unexpected electron-density dependence not captured by our analysis above. In particular, for increasing electron concentration the resistivity has been observed to decrease and finally saturate to the in-plane phonon contribution [Eq. (25)] at large densities.

While it may be tempting to think that this behavior originates from the screening of the deformation potential at increasing electron density, our analysis shows that this is not the case. Indeed, for $T > T_{BG}^{(l)}$, Q is cut off at $2k_F$. This, together with the fact that $Q_{TF} \propto k_F$, implies that the screening factor in Eq. (6) does not introduce any additional density dependence into the scattering rate. Moreover, if this was a relevant effect, it should appear in nonsuspended samples as well.

The in-plane phonon contribution [Eq. (25)] seems sufficient to describe the behavior of nonsuspended samples, where flexural (out-of-plane) deformations are suppressed by the direct contact with a substrate. In graphene samples on very rough substrates small out-of-plane fluctuations could still survive due to the nonperfect adhesion of the membrane to the surface of the substrate.

In contrast, flexural phonons can become relevant in suspended devices. We now turn to analyze their effect along the same line as for the in-plane modes above.

B. Flexural phonons

The analysis of the resistivity due to flexural phonon modes is more involved due to the presence of two phonons with wave vectors \mathbf{q}_1 and \mathbf{q}_2 at each interaction vertex. These yield four possible processes involving double absorption, double emission, or mixed absorption-emission terms in the scattering rate. In addition, four relevant wave-vector scales come into play, namely, $q_T^{(h)}$, Q_{GD} , q_* , and k_{F} , related to temperature ($\hbar \omega_{q_T^{(h)}}^{(h)} = k_{\text{B}}T$), screening, tension, and electron concentration, respectively. A further ultraviolet scale, corresponding to a Debye energy of order $\hbar \omega_{1/a}^{(h)} \sim 100$ meV, is assumed to provide the largest energy scale. For temperatures higher than $\hbar \omega_{1/a}^{(h)}/k_{\text{B}}$ the straightforward expansion of the two Bose distributions yields a scattering rate depending on temperature as T^2 . However, at those energies the elastic treatment of the membrane as well as the elastic approximation in the scattering rate may be questionable. We thus focus on lower temperatures which are relevant to experiments.

The collision integral including all emission and absorption processes for scattering of electrons and flexural phonons has the form

$$C^{(h)}(f_{\mathbf{k}}) = \frac{2\pi}{\hbar} \sum_{\mathbf{q}_{1},\mathbf{q}_{2}} W^{(h)}_{\mathbf{k};\mathbf{k}',\mathbf{q}_{1},\mathbf{q}_{2}} [f_{\mathbf{k}'}(1-f_{\mathbf{k}})n^{(h)}_{\mathbf{q}_{1}}n^{(h)}_{\mathbf{q}_{2}} - f_{\mathbf{k}}(1-f_{\mathbf{k}'})(1+n^{(h)}_{\mathbf{q}_{1}})(1+n^{(h)}_{\mathbf{q}_{2}})] \delta(\boldsymbol{\epsilon}_{\mathbf{k}} - \boldsymbol{\epsilon}_{\mathbf{k}'} - \hbar\omega^{(h)}_{\mathbf{q}_{1}} - \hbar\omega^{(h)}_{\mathbf{q}_{2}}) \\ + \frac{2\pi}{\hbar} \sum_{\mathbf{q}_{1},\mathbf{q}_{2}} W^{(h)}_{\mathbf{k},\mathbf{q}_{1},\mathbf{q}_{2};\mathbf{k}'} [f_{\mathbf{k}'}(1-f_{\mathbf{k}})(1+n^{(h)}_{\mathbf{q}_{1}})(1+n^{(h)}_{\mathbf{q}_{2}}) - f_{\mathbf{k}}(1-f_{\mathbf{k}'})n^{(h)}_{\mathbf{q}_{1}}n^{(h)}_{\mathbf{q}_{2}}] \delta(\boldsymbol{\epsilon}_{\mathbf{k}} - \boldsymbol{\epsilon}_{\mathbf{k}'} - \hbar\omega^{(h)}_{\mathbf{q}_{1}} + \hbar\omega^{(h)}_{\mathbf{q}_{2}}) \\ + \frac{2\pi}{\hbar} \sum_{\mathbf{q}_{1},\mathbf{q}_{2}} W^{(h)}_{\mathbf{k},\mathbf{q}_{2};\mathbf{k}',\mathbf{q}_{1}} [f_{\mathbf{k}'}(1-f_{\mathbf{k}})n^{(h)}_{\mathbf{q}_{1}}(1+n^{(h)}_{\mathbf{q}_{2}}) - f_{\mathbf{k}}(1-f_{\mathbf{k}'})(1+n^{(h)}_{\mathbf{q}_{1}})n^{(h)}_{\mathbf{q}_{2}}] \delta(\boldsymbol{\epsilon}_{\mathbf{k}} - \boldsymbol{\epsilon}_{\mathbf{k}'} - \hbar\omega^{(h)}_{\mathbf{q}_{1}} + \hbar\omega^{(h)}_{\mathbf{q}_{2}}) \\ + \frac{2\pi}{\hbar} \sum_{\mathbf{q}_{1},\mathbf{q}_{2}} W^{(h)}_{\mathbf{k},\mathbf{q}_{1};\mathbf{k}',\mathbf{q}_{2}} [f_{\mathbf{k}'}(1-f_{\mathbf{k}})(1+n^{(h)}_{\mathbf{q}_{1}})n^{(h)}_{\mathbf{q}_{2}} - f_{\mathbf{k}}(1-f_{\mathbf{k}'})n^{(h)}_{\mathbf{q}_{1}}(1+n^{(h)}_{\mathbf{q}_{2}})] \delta(\boldsymbol{\epsilon}_{\mathbf{k}} - \boldsymbol{\epsilon}_{\mathbf{k}'} + \hbar\omega^{(h)}_{\mathbf{q}_{1}} - \hbar\omega^{(h)}_{\mathbf{q}_{2}})$$

$$(26)$$

with

$$W_{\mathbf{k};\mathbf{k}',\mathbf{q}_{1},\mathbf{q}_{2}}^{(h)} = \delta_{\mathbf{k},\mathbf{k}'+\mathbf{q}_{1}+\mathbf{q}_{2}} |\langle \mathbf{k} | w_{\mathbf{q}_{1},\mathbf{q}_{2}}^{(h)} | \mathbf{k}' \rangle|^{2}.$$
(27)

A lengthy but straightforward calculation analogous to the case of in-plane modes above yields the linearized collision integral of the form in Eq. (11) with the transport scattering rate

$$\frac{1}{\tau_{\mathbf{k}}} = \frac{2\pi}{\hbar} \sum_{\mathbf{q}_{1},\mathbf{q}_{2}} 2 \frac{\partial n_{\mathbf{q}_{1}}^{0(h)}}{\partial \omega_{\mathbf{q}_{1}}^{(h)}} \frac{\partial n_{\mathbf{q}_{2}}^{0(h)}}{\partial \omega_{\mathbf{q}_{2}}^{(h)}} \frac{k_{\mathrm{B}}T}{\hbar} (1 - \cos \theta)$$

$$\times |\langle \mathbf{k} + \mathbf{Q} | w_{\mathbf{q}_{1},\mathbf{q}_{2}}^{(h)} | \mathbf{k} \rangle|^{2} \delta(\boldsymbol{\epsilon}_{\mathbf{k}+\mathbf{Q}} - \boldsymbol{\epsilon}_{\mathbf{k}})$$

$$\times \left[\frac{\omega_{\mathbf{q}_{1}}^{(h)} + \omega_{\mathbf{q}_{2}}^{(h)}}{1 + n_{\mathbf{q}_{1}}^{0(h)} + n_{\mathbf{q}_{2}}^{0(h)}} + \frac{\omega_{\mathbf{q}_{1}}^{(h)} - \omega_{\mathbf{q}_{2}}^{(h)}}{n_{\mathbf{q}_{2}}^{0(h)} - n_{\mathbf{q}_{1}}^{0(h)}} \right]$$
(28)

with θ the angle between the electronic wave vectors **k** and $\mathbf{k}+\mathbf{Q}$ and $\mathbf{Q}=\mathbf{q}_1+\mathbf{q}_2$ the total wave vector transferred to the phonons in the scattering process.

The general considerations in Sec. III A hold for flexural phonons as well. In particular, the on-shell condition in Eq. (20) as well as Eq. (21) remain valid. The matrix element of the electron-phonon coupling is given from Eq. (8) as

$$\begin{split} \langle \mathbf{k} | w_{\mathbf{q}_{1},\mathbf{q}_{2}}^{(h)} | \mathbf{k} + \mathbf{Q} \rangle &= -\frac{q_{1}q_{2}\xi_{\mathbf{q}_{1}}^{(h)}\xi_{\mathbf{q}_{2}}^{(h)}}{4} [g_{1}^{(\mathrm{sc})}(Q) \cos \phi (1 + e^{i\theta}) \\ &- ig_{2}(e^{i(\psi + \phi_{\mathbf{k}} + \theta)} - e^{-i(\psi + \phi_{\mathbf{k}})})]. \end{split}$$

Temperature enters the scattering rate Eq. (19) via the Bose distributions and cuts off the relevant phonon momenta at $q_1, q_2 \leq q_T^{(h)}$. Contrary to what happens for in-plane modes, this is the even for $q_T^{(h)} \geq 2k_{\rm F}$ (i.e., for $T \geq T_{\rm BG}^{(h)}$ with $T_{\rm BG}^{(h)} = \hbar \omega_{2k_{\rm F}}^{(h)}/k_{\rm B}$ the Bloch-Grüneisen temperature of flexural phonons). Indeed, while the total scattering wave vector \mathbf{Q} is bounded by the on-shell condition to fulfil $Q \leq 2k_{\rm F}$, each individual q_1 and q_2 can be large, provided that $|\mathbf{q}_1 - \mathbf{q}_2|$ $\leq q_T^{(h)}$. In this regime, scattering at all angles is possible and the dominant electron-phonon coupling mechanism is via the unscreened deformation potential.

In the opposite limit of low temperature where $T \ll T_{BG}^{(h)}$ (i.e., for $q_T^{(h)} \ll 2k_{\rm F}$) the scattering rate is dominated by small angle scattering with $1 - \cos \theta \sim (q_T^{(h)}/2k_{\rm F})^2 \ll 1$. In this regime, screening suppresses the deformation potential coupling in Eq. (29), yielding $g_1^{(sc)}(Q) \sim g_1 q_T^{(h)} / Q_{TF} \ll g_1$. This suppression favors the unscreened gauge-field coupling g_2 for $q_T^{(h)} \ll Q_{\rm GD}$ (i.e., for $T \ll T_{\rm GD}^{(h)}$ with $T_{\rm GD}^{(h)} = \hbar \omega_{Q_{\rm GD}}^{(h)}/k_{\rm B}$).

Tension affects the phonon spectra yielding a linear dispersion for $q < q_*$ and a quadratic one for $q > q_*$. As the density of phonon states is much higher in the region of the quadratic spectrum, the dispersion relation which dominantly contributes to the resistivity is linear if $q_T^{(h)} \ll q_*$ and quadratic for $q_T^{(h)} \ge q_*$. This DOS suppression at low energy is not accompanied by a change in the flexural-phonon coupling which remains quadratic even in presence of tension as the reflection symmetry with respect to the plane is preserved. This is the basic mechanism suppressing the contribution to the resistivity of flexural phonons with respect to in-plane ones.

It is possible to deduce the relevant temperature and electron concentration dependence of the scattering rate by simple power counting, once the relevant momenta are identified. Indeed, for $q \leq q_T^{(h)}$, one has $n_{\mathbf{q}}^{(h)} \sim k_{\mathrm{B}}T/\hbar\omega_{\mathbf{q}}^{(h)}$ and the scattering rate is given by

$$\frac{1}{\tau_{\mathbf{k}}} \simeq \frac{2\pi}{\hbar} \sum_{\mathbf{q}_1, \mathbf{q}_2} 4 \frac{k_{\mathrm{B}}^2 T^2}{\hbar^2 \omega_{\mathbf{q}_1}^{(h)} \omega_{\mathbf{q}_2}^{(h)}} (1 - \cos \theta)$$
$$\times |\langle \mathbf{k} + \mathbf{Q} | w_{\mathbf{q}_1, \mathbf{q}_2}^{(h)} | \mathbf{k} \rangle|^2 \delta(\boldsymbol{\epsilon}_{\mathbf{k}+\mathbf{Q}} - \boldsymbol{\epsilon}_{\mathbf{k}}), \qquad (29)$$

where the factor 4 accounts for all emission-absorption processes of the two phonons. Introducing the total and relative momenta **Q** and $\mathbf{q} = \mathbf{q}_1 - \mathbf{q}_2$, the transport scattering rate for electrons at the Fermi level scales as

$$\frac{1}{\tau_{k_{\rm F}}} \sim T^2 \int^{q_T^{(h)}} dqq \int^{\min[q_T^{(h)}, 2k_{\rm F}]} dQ \\ \times \left(\frac{Q}{2k_{\rm F}}\right)^2 \left(\frac{Q}{Q+Q_{\rm TF}}\right)^{2\lambda} \frac{q_1^2 q_2^2}{\omega_{\mathbf{q}_1}^{(h)2} \omega_{\mathbf{q}_2}^{(h)2}}.$$
 (30)

Here $\lambda = 0$ for $T \ll T_{GD}^{(h)}$ when the gauge-field coupling is dominant while $\lambda = 1$ for $T \gg T_{GD}^{(h)}$ when the screened deformation potential dominates. In principle seven different regimes can be identified, according to the relative magnitude of the relevant wave vectors.

At low temperatures $T \ll T_{GD}^{(h)} \ll T_{BG}^{(h)}$, corresponding to $q_T^{(h)} \ll Q_{GD} \ll 2k_{\rm F}$, $\lambda = 0$ and small angle scattering dominates the scattering rate. We can rescale all wave numbers by $q_T^{(h)}$ and find two regimes.

and find two regimes. (I) For $q_* \ll q_T^{(h)}$ the relevant dispersion is $\omega \sim q^2$, yielding $q_T^{(h)} \sim \sqrt{T}$ and $1/\tau_{k_{\rm F}} \sim T^{5/2}/k_{\rm F}^2$. (II) For $q_T^{(h)} \ll q_*$ the relevant dispersion is $\omega \sim q$, yielding $q_T^{(h)} \sim T$ and $1/\tau_{k_{\rm F}} \sim T^7/k_{\rm F}^2$.

As pointed out before,¹⁰ the first regime with low tension shows a logarithmic infrared singularity. For a sufficiently large membrane, these singularities are regularized by a temperature-dependent infrared cutoff related to the nonlinear coupling of bending and stretching energies in the elastic Lagrangian.^{8,10} Small tension or finite-size effects yield alternative infrared cutoffs modifying the value of the scattering rates by numerical prefactors of order one.

The expansions above show that, in the first case with very weak tension $(q_* \ll q_T^{(h)} \ll Q_{GD})$, the scattering rate due to flexural phonons has a $T^{5/2}$ temperature dependence and is larger than the corresponding one due to in-plane modes, which scales as T^4 . In contrast, for $q_T^{(h)} \ll q_* \ll Q_{\text{GD}}$, tension suppresses the flexural contribution to the subdominant T^7 term, which allows in-plane scattering to dominate the electron-phonon scattering contribution to the resistivity at low temperatures.

At intermediate temperatures $T_{GD}^{(h)} \ll T \ll T_{BG}^{(h)}$, corresponding to $Q_{\text{GD}} \ll q_T^{(h)} \ll 2k_{\text{F}}$, small angle scattering still dominates the scattering rate while $\lambda = 1$. Screening thus yields an ad-ditional factor $(q_T^{(h)}/Q_{\text{TF}})^2$ in the scattering rate. Rescaling all wave numbers by $q_T^{(h)}$ we find two regimes similar to the previous analysis.



FIG. 2. The dependence of the resistivity due to scattering off flexural modes on temperature T and electron density n. The gray area identifies the region $q_* > q_T^{(h)}$ where the relevant flexural phonon dispersion is dominated by tension and $\omega_{\mathbf{q}}^{(h)} \simeq \alpha q$.

(III) For $q_* \ll q_T^{(h)}$ the relevant dispersion is $\omega \sim q^2$, yield-ing $q_T^{(h)} \sim \sqrt{T}$ and $1/\tau_{k_{\rm F}} \sim T^{7/2}/k_{\rm F}^4$. (IV) For $q_T^{(h)} \ll q_*$ the relevant dispersion is $\omega \sim q$, yielding $q_T^{(h)} \sim T$ and $1/\tau_{k_{\rm F}} \sim T^9/k_{\rm F}^4$. Finally, in the high-temperature limit $T \gg T_{\rm BG}^{(h)}$, corresponding to $q_T^{(h)} \gg 2k_{\rm F}$, large angle scattering is possible for $q_T^{(h)} \gg k_{\rm F}$, which yield the dominant contribution to the $q_1, q_2 > k_{\rm F}$, which yield the dominant contribution to the scattering rate. In this regime $\lambda = 1$ and the total wave vector Q is cut off at $2k_{\rm F}$ due to the on-shell condition while q is imited by $q_T^{(h)}$. In the case of strong tension $q_* \ge q_T^{(h)}$ the suppression of the phononic DOS at low energy shifts the dominant momenta to large values of order $q \sim q_T^{(h)}$. In contrast, small tension $q_* \ll q_T^{(h)}$ tends to favor low momenta down to q_* or $k_{\rm F}$, whichever is smaller. We identify three regimes.

(V) For $q_* \ll 2k_{\rm F} \ll q_T^{(h)}$ the relevant dispersion is $\omega \sim q^2$, yielding a dominant contribution for small wave numbers

down to $q \sim k_{\rm F}$ resulting in $1/\tau_{k_{\rm F}} \sim T^2/k_{\rm F}$. (VI) For $2k_{\rm F} \ll q_* \ll q_T^{(h)}$ the relevant dispersion is $\omega \sim q^2$, yielding a dominant contribution for small wave numbers down to $q \sim q_*$ resulting in $1/\tau_{k_{\rm F}} \sim T^2 k_{\rm F}$.

(VII) For $2k_{\rm F} \ll q_{\star}^{(h)} \ll q_{\star}$ the relevant dispersion is $\omega \sim q$, yielding $q_T^{(h)} \sim T$ and $1/\tau_{k_{\rm F}} \sim T^4 k_{\rm F}$.

It has to be noted that the T^2 scaling in regime V stems from the relevant q^2 dispersion of flexural modes with low tension and is not trivially obtained from the hightemperature expansion of the two Bose distributions, unlike in the case of in-plane phonons. In this case, in fact, the q_1 and q_2 momenta are still limited by $q_T^{(h)}$.

The corresponding dependence of the resistivity on temperature and electron density in the seven regions above is summarized in the diagram of Fig. 2.

By a more explicit evaluation of Eq. (28) we calculate the scattering rate due to electron-phonon coupling for flexural modes in the seven regimes above, yielding

$$\begin{split} \frac{1}{\tau_{k_{\rm F}}} &\simeq C_{\rm G} \frac{(k_{\rm B}T)^{5/2}}{(\hbar\beta)^{1/2}\beta^4(2k_{\rm F})^2} & \text{in region I,} \\ \frac{1}{\tau_{k_{\rm F}}} &\simeq C_{\rm G} \frac{(k_{\rm B}T)^7}{(\hbar\alpha)^5 \alpha^4(2k_{\rm F})^2} & \text{in region II,} \\ \frac{1}{\tau_{k_{\rm F}}} &\simeq C \frac{(k_{\rm B}T)^{7/2}}{(\hbar\beta)^{3/2}\beta^4(2k_{\rm F}Q_{\rm TF})^2} & \text{in region III,} \\ \frac{1}{\tau_{k_{\rm F}}} &\simeq C \frac{(k_{\rm B}T)^9}{(\hbar\alpha)^7 \alpha^4(2k_{\rm F}Q_{\rm TF})^2} & \text{in region IV,} \\ \frac{1}{\tau_{k_{\rm F}}} &\simeq C \frac{(k_{\rm B}T)^2}{\beta^4 2k_{\rm F}} & \text{in region V,} \\ \frac{1}{\tau_{k_{\rm F}}} &\simeq C \frac{(k_{\rm B}T)^2}{\beta^4 q_*^2} & \text{in region VI,} \\ \frac{1}{\tau_{k_{\rm F}}} &\simeq C \frac{(k_{\rm B}T)^2 2k_{\rm F}}{\alpha^4(\hbar\alpha)^2} & \text{in region VI,} \end{split}$$

with $C \simeq g_1^2 / (2\pi)^3 \rho_0^2 \hbar^2 v$ and $C_G \simeq C g_2^2 / g_1^2$, up to numerical prefactors of order one.

C. In-plane vs flexural phonons

Our analysis allows us to compare the contribution to the resistivity of in-plane and flexural modes. In order to quantify the importance of these two contributions at a given temperature, it has to be pointed out that the Bloch-Grüneisen temperatures for in-plane and flexural phonons can be significantly different, in particular in the low-tension regime where out-of-plane modes have a soft quadratic dis-persion. For graphene one finds $T_{BG}^{(l)} \approx 50\tilde{n}^{1/2}$ K and $T_{BG}^{(r)} \approx 0.7T_{BG}^{(l)}$ while (in the absence of tension) $T_{BG}^{(h)} \approx 0.4\tilde{n}$ K with $\tilde{n} = n/10^{12}$ cm⁻² the rescaled electron density. In paral-lel, with $Q_{GD} \approx 0.2 \cdot 2k_{F}$, one has $T_{GD}^{(l,r)} \approx 0.2T_{BG}^{(l,r)}$ and $T_{GD}^{(h)} \approx 0.04T_{BG}^{(h)}$. In the absence of tension at $T = T_{BG}^{(l)}$ the estimates above yield a ratio between the scattering rate due to flexural and in-plane phonons of $2.5\tilde{n}^{-1/2}$ and for higher temperatures the flexural modes will be even more dominant.

In practice, at the present electron concentrations for suspended graphene samples, in the absence of tension the flexural-phonon contribution to the resistivity should dominate over the in-plane one at any temperature, showing a crossover between a $T^{5/2}$ to a $T^{7/2}$ dependence around $T_{GD}^{(h)}$, and between $T^{7/2}$ and T^2 around $T_{BG}^{(h)}$. The main reason why the effect of flexural modes does not appear in experiments is due to the suppression of the flexural phonon contribution to the resistivity by the sample-specific tension. Actually, due to the negative thermal-expansion coefficient of graphene,³⁵ tension is itself a temperature-dependent quantity. This suppression leaves the in-plane contribution as the dominant scattering mechanism, yielding a linear-T dependence compatible with experiments.



FIG. 3. (Color online) The combined contributions to the resistivity due to in-plane and flexural-phonons $\Delta \rho$ as a function of the temperature T for three different electron densities \tilde{n} =0.05,0.15,0.3 (dashed-dotted, dashed, and continuous line, respectively). Here we assume a tension $\tilde{\gamma}=1$ and a deformation potential coupling $\tilde{g}_1=10$. Inset: same plot as in the main figure but for stronger tension $\tilde{\gamma}=20$. Notice the almost perfect linear-T scaling, independent of density.

When tension is present, in the experimentally relevant regimes $q_* \ll 2k_{\rm F} \ll q_T^{(h)}$ and $2k_{\rm F} \ll q_* \ll q_T^{(h)}$ the contribution to the resistivity from flexural phonons is approximated by

$$\Delta \rho_{\rm flex} \simeq \frac{h}{e^2} 10^{-9} \frac{\tilde{g}_1^2}{\tilde{n} + \tilde{\gamma}} \tilde{T}^2 \tag{31}$$

with the rescaled tension $\tilde{\gamma} = \gamma/2 \times 10^{-2}$ Kg s⁻². The value $\tilde{\gamma} = 1$ corresponds to the condition $q_* = 2k_{\rm F}$ at the density $\tilde{n} = 1$. Comparing Eq. (25) and (31) we thus get

$$\frac{\Delta \rho_{\text{flex}}}{\Delta \rho_{\text{in}}} \simeq \frac{1}{20} \frac{\widetilde{T}}{\widetilde{n} + \widetilde{\gamma}}.$$
(32)

We can then estimate the minimal tension needed to suppress the flexural contribution by imposing the ratio in Eq. (32) to be smaller than unity at room temperature. Considering that in typical current suspended samples $\tilde{n} < 1$, this results in a tension $\tilde{\gamma} \approx 15$, corresponding to a strain of about 10^{-3} . These estimates are reliable as long as we do not enter the regime of very high tension $2k_{\rm F} \ll q_T^{(h)} \ll q_*$, i.e., for $\tilde{\gamma} < 3\tilde{T}$, which is usually easily fulfilled for $T > T_{\rm BG}^{(l)}$.

Thus rather weak tension is sufficient to suppress the flexural contribution in favor of the in-plane one. This is true for temperatures up to $\tilde{T}_c \simeq 20(\tilde{n} + \tilde{\gamma})$ where the crossover between the in-plane-dominated to the flexural-phonondominated resistivity takes place. The observation of the crossover between these two regimes would provide information about the otherwise unknown value of tension in the sample. This prediction could be tested, for example, in graphene samples mounted on break junctions where tension can be controllably tuned or in flakes clamped on a single side with an STM tip as a drain contact.

In Fig. 3 we plot the temperature-dependent component of the resistivity $\Delta \rho = \Delta \rho_{in} + \Delta \rho_{flex}$ according to Eqs. (25) and (31). The combined contributions of in-plane and flexural phonons are shown for different densities in the experimentally relevant range. Even in the presence of tension on the order of $\tilde{\gamma}=1$, the contribution from flexural phonons can still significantly affect the value of the resistivity. This results in a slight deviation from the purely linear-*T* dependence due to in-plane modes. In this case, a residual density dependence is observable, stemming from the regime $q_* \ll 2k_F \ll q_T^{(h)}$, in qualitative agreement with experiments on suspended graphene.¹⁹ In contrast, the inset in Fig. 3 shows the density-independent *T*-linear resistivity at larger tension ($\tilde{\gamma}=20$).

A quantitative understanding of the density dependence observed in experiments would require the knowledge of the sample-specific tension, as well as the inclusion of temperature-dependent screening of charged impurities,²⁹ of Altshuler-Aronov corrections,³⁰ and possibly of further nonintrinsic electron-phonon coupling mechanisms (e.g., capacitive coupling to a backgate as well as buckling). These issues are beyond the scope of the present paper.

IV. CONCLUSIONS

In summary, the interplay between the electronic and phononic degrees of freedom in suspended graphene membranes offers a rich scenario which can be addressed in current transport measurements.

Here we analyzed the contribution to the resistivity of suspended graphene due to electron-phonon scattering. We discussed the competition between acoustic in-plane and flexural distortions in various temperature regimes. We focused on the intrinsic electron-phonon coupling in graphene due to the interaction of electrons with elastic deformations, taking into account both the (screened) deformation potential and the fictitious (or synthetic) gauge-field coupling. This should be appropriate when the graphene membrane is flat on scales of the wavelength of those phonons which dominate the temperature-dependent resistivity. Further nonuniversal coupling mechanisms exist, e.g., via the capacitive interaction of the membrane with a back gate or the breaking of the reflection symmetry (e.g., due to buckling). While we do not discuss these in the present work, they yield a sample-specific linear coupling for those flexural phonons whose wavelength exceeds the typical length scale over which the membrane deviates from a planar configuration. In the presence of tension, these phonons would result in a T-dependent contribution to the resistivity analogous to inplane modes.

We find that, for the electron densities achievable in suspended graphene, flexural phonons should dominate over inplane ones at any temperature in the absence of tension. In particular, the component of the resistivity due to flexural phonons should show a $T^{5/2}$ dependence for $T \ll T_{GD}^{(h)}$ associated with the fictitious gauge-field coupling. For $T_{GD}^{(h)} \ll T$ $\ll T_{BG}^{(h)}$ the $T^{7/2}$ dependence stems from the dominant coupling via the screened deformation potential while for T $\gg T_{BG}^{(h)}$ screening is irrelevant and the resistivity scales as T^2 . A sample-specific tension induced by the contacts yields a stiffening of the flexural dispersion, corresponding to a suppressed phonon density of states while the reflection symmetry with respect to the plane protects their weak quadratic coupling. As a result, tension suppresses the flexuralphonons contribution to the resistivity. We point out that, due to the negative thermal-expansion coefficient of graphene, tension in real suspended samples is itself temperature dependent.

We conclude that it is due to the nonuniversal tensioninduced suppression of the contribution due to flexural modes that experiments seem to show a resistivity dominated by in-plane phonons alone. The latter yield a linear temperature-dependent resistivity for $T \gg T_{BG}^{(l)}$, in qualitative agreement with experiments. This contribution is, however, independent of electron density even in the presence of electronic screening and cannot account for the observed density dependence in suspended samples. A density dependence is induced as long as the flexural phonons contribute significantly to the resistivity which is the case for sufficiently weak tension. It would be interesting to probe these issues in samples with a controllable degree of tension, like suspended graphene in break junctions or in suspended flakes clamped on a single side with an STM tip as a contact.

Note added. After completion of this manuscript a new experiment appeared,³⁶ probing the T^2 dependence of the resistivity in suspended graphene. The data are compatible with the contribution due to flexural-phonon scattering in devices with weak tension. The theoretical treatment in Ref. 36 is analogous to the high-temperature regime of our analysis (regions V, VI, and VII); see also Ref. 37.

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- ¹K. S. Novoselov, A. K. Geim, S. V. Morozov, D. Jiang, Y. Zhang, S. V. Dubonos, I. V. Grigorieva, and A. A. Firsov, Science **306**, 666 (2004); K. S. Novoselov, A. K. Geim, S. M. Morozov, D. Jiang, M. I. Katsnelson, I. V. Grigorieva, S. V. Dubonos, and A. A. Firsov, Nature (London) **438**, 197 (2005).
- ²Y. Zhang, Y.-W. Tan, H. L. Stormer, and P. Kim, Nature (London) **438**, 201 (2005).
- ³J. C. Meyer, A. K. Geim, M. I. Katsnelson, K. S. Novoselov, T. J. Booth, and S. Roth, Nature (London) **446**, 60 (2007).
- ⁴J. Scott Bunch, A. M. van der Zande, S. S. Verbridge, I. W. Frank, D. M. Tanenbaum, J. M. Parpia, H. G. Craighead, and P. L. McEuen, Science **315**, 490 (2007).
- ⁵E.-A. Kim and A. H. Castro Neto, EPL 84, 57007 (2008).
- ⁶R. E. Peierls, Ann. Inst. Henri Poincare **5**, 177 (1935).
- ⁷L. D. Landau, Phys. Z. Sowjetunion **11**, 26 (1937).
- ⁸D. R. Nelson and L. Peliti, J. Phys. (Paris) **48**, 1085 (1987).
- ⁹M. Paczuski, M. Kardar, and D. R. Nelson, Phys. Rev. Lett. **60**, 2638 (1988).
- ¹⁰E. Mariani and F. von Oppen, Phys. Rev. Lett. **100**, 076801 (2008); **100**, 249901(E) (2008).
- ¹¹L. M. Woods and G. D. Mahan, Phys. Rev. B 61, 10651 (2000).
- ¹²H. Suzuura and T. Ando, Phys. Rev. B **65**, 235412 (2002).
- ¹³M. Vozmediano, M. Katsnelson, and F. Guinea, arXiv:1003.5179, Phys. Rep. (to be published).
- ¹⁴ V. M. Pereira and A. H. Castro Neto, Phys. Rev. Lett. **103**, 046801 (2009).
- ¹⁵F. Guinea, M. I. Katsnelson, and A. K. Geim, Nat. Phys. 6, 30 (2010).
- ¹⁶A. Kozikov, A. Savchenko, B. Narozhny, and A. Shytov, Phys. Rev. B 82, 075424 (2010).
- ¹⁷S. V. Morozov, K. S. Novoselov, M. I. Katsnelson, F. Schedin,

- D. C. Elias, J. A. Jaszczak, and A. K. Geim, Phys. Rev. Lett. **100**, 016602 (2008).
- ¹⁸J.-H. Chen, C. Jang, S. Xiao, M. Ishigami, and M. S. Fuhrer, Nat. Nanotechnol. **3**, 206 (2008).
- ¹⁹K. I. Bolotin, K. J. Sikes, J. Hone, H. L. Stormer, and P. Kim, Phys. Rev. Lett. **101**, 096802 (2008).
- ²⁰See, e.g., W. A. Harrison, *Solid State Theory* (McGraw-Hill, New York, 1970).
- ²¹E. H. Hwang and S. Das Sarma, Phys. Rev. B **77**, 115449 (2008).
- ²²P. R. Wallace, Phys. Rev. **71**, 622 (1947).
- ²³D. P. DiVincenzo and E. J. Mele, Phys. Rev. B 29, 1685 (1984).
- ²⁴L. D. Landau and E. M. Lifshitz, *Theory of Elasticity* (Pergamon, New York, 1986).
- ²⁵Typical parameters for graphene are $\kappa = 1 \text{ eV}$, $\mu \approx 4\lambda$ =9 eV Å⁻², and $\rho_0 \approx 7.6 \times 10^{-7} \text{ kg m}^{-2}$.
- ²⁶E. H. Hwang and S. Das Sarma, Phys. Rev. B **75**, 205418 (2007).
- ²⁷ F. von Oppen, F. Guinea, and E. Mariani, Phys. Rev. B 80, 075420 (2009).
- ²⁸M. Müller, M. Bräuninger, and B. Trauzettel, Phys. Rev. Lett. **103**, 196801 (2009).
- ²⁹E. H. Hwang and S. Das Sarma, Phys. Rev. B **79**, 165404 (2009).
- ³⁰ V. V. Cheianov and V. I. Fal'ko, Phys. Rev. Lett. **97**, 226801 (2006).
- ³¹L. D. Landau and E. M. Lifshitz, *Physical Kinetics* (Pergamon, New York, 1986).
- ³²L. Pietronero, S. Strässler, H. R. Zeller, and M. J. Rice, Phys. Rev. B 22, 904 (1980).

- ³³T. Stauber, N. M. R. Peres, and F. Guinea, Phys. Rev. B **76**, 205423 (2007).
- ³⁴J. K. Viljas and T. T. Heikkilä, Phys. Rev. B **81**, 245404 (2010).
- ³⁵W. Bao, F. Miao, Z. Chen, H. Zhang, W. Jang, C. Dames, and C. N. Lau, Nat. Nanotechnol. 4, 562 (2009).
- ³⁶E. Castro, H. Ochoa, M. Katsnelson, R. Gorbachev, D. Elias, K. Novoselov, A. Geim, and F. Guinea, arXiv:1008.2522 (unpublished).
- ³⁷H. Ochoa, E. Castro, M. Katsnelson, and F. Guinea, arXiv:1008.2523 (unpublished).